Silicon P-Channel MOS FET

HITACHI

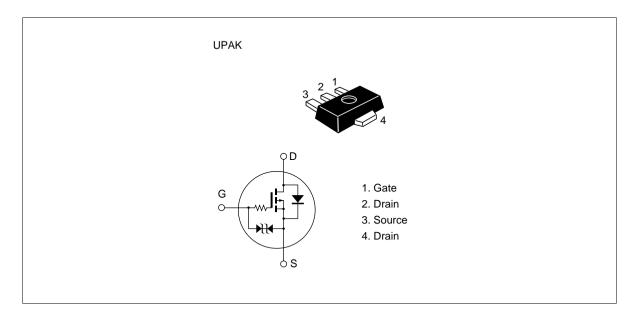
Application

High speed power switching

Features

- Low on-resistance
- High speed switching
- Low drive current
- 2.5 V gate drive device can be driven from 3 V source

Outline





Absolute Maximum Ratings ($Ta = 25^{\circ}C$)

Item	Symbol	Ratings	Unit	
Drain to source voltage	V _{DSS}	-20	V	
Gate to source voltage	V_{GSS}	±20	V	
Drain current	I _D	-2	А	
Drain peak current	I _{D(pulse)} *1	-4	А	
Body to drain diode reverse drain current	I _{DR}	-2	А	
Channel dissipation	Pch*2	1	W	
Channel temperature	Tch	150	°C	
Storage temperature	Tstg	-55 to +150	°C	

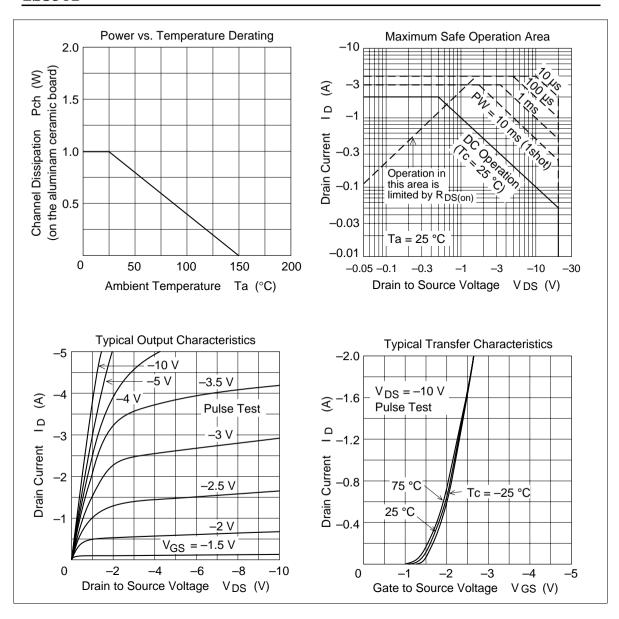
Notes: 1. PW \leq 10 μ s, duty cycle \leq 1%

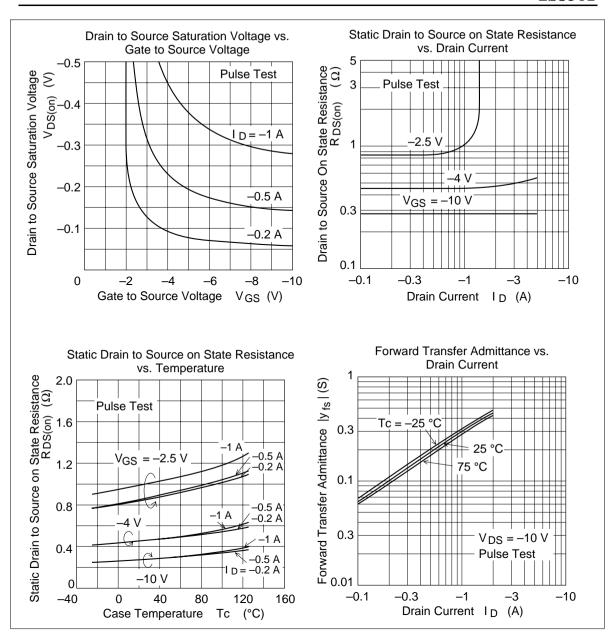
- 2. Value on the alumina ceramic board (12.5×20×0.7 mm)
- 3. Marking is "RY".

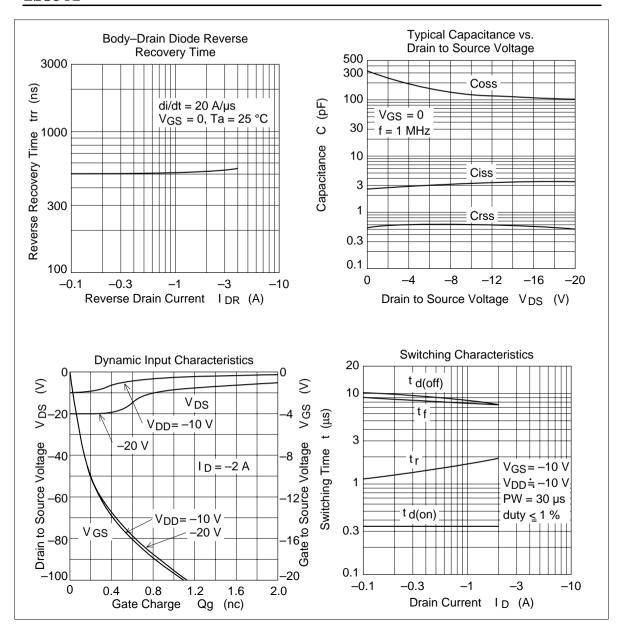
Electrical Characteristics ($Ta = 25^{\circ}C$)

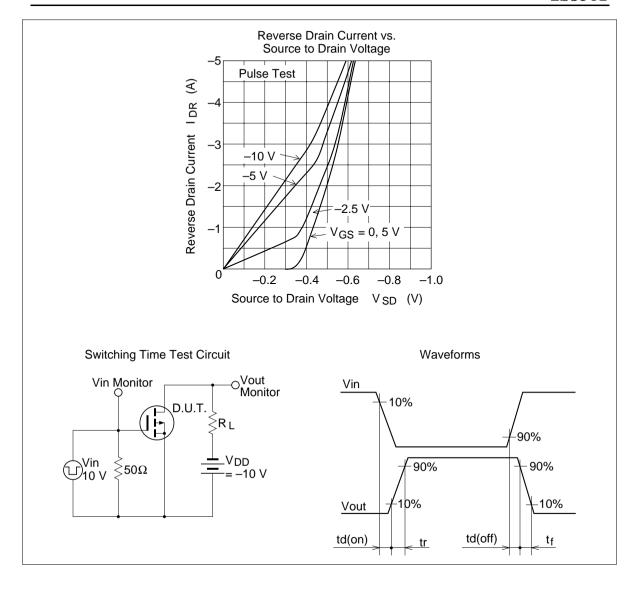
Item	Symbol	Min	Тур	Max	Unit	Test conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	-20	_	_	V	$I_D = -10 \text{ mA}, V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	±20	_	_	V	$I_G = \pm 100 \ \mu A, \ V_{DS} = 0$
Gate to source leak current	I _{GSS}	_	_	±10	μΑ	$V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I _{DSS}	_	_	-10	μΑ	$V_{DS} = -16 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{\text{GS(off)}}$	-0.5	_	-1.5	V	$I_D = -1 \text{ mA}, V_{DS} = -10 \text{ V}$
Static drain to source on state	$R_{\scriptscriptstyle DS(on)}$	_	0.28	0.4	Ω	$I_D = -1 A, V_{GS} = -10 V$
resistance		_	0.85	1.5	Ω	$I_D = -0.4 \text{ A}, V_{GS} = -2.5 \text{ V}$
Forward transfer admittance	$ y_{fs} $	0.15	0.3	_	S	$I_{D} = -1 A, V_{DS} = -10 V$
Input capacitance	Ciss	_	3.2	_	pF	$V_{DS} = -10 \text{ V}, V_{GS} = 0,$
Output capacitance	Coss	_	130	_	pF	f = 1 MHz
Reverse transfer capacitance	Crss	_	0.6	_	pF	
Turn-on delay time	$t_{d(on)}$	_	350	_	ns	$I_D = -1 A, V_{GS} = -10 V,$
Rise time	t,	_	1650	_	ns	$R_L = 10 \Omega$
Turn-off delay time	t _{d(off)}	_	7280	_	ns	
Fall time	t _f	_	6950	_	ns	
Body to drain diode forward voltage	V_{DF}	_	-1.0	_	V	$I_F = -2 \text{ A}, V_{GS} = 0$
Body to drain diode reverse recovery time	t _{rr}	_	530	_	ns	$I_F = -2 \text{ A}, V_{GS} = 0,$ $di_F/dt = 20 \text{ A}/\mu\text{s}$

Note: 1. Pulse test

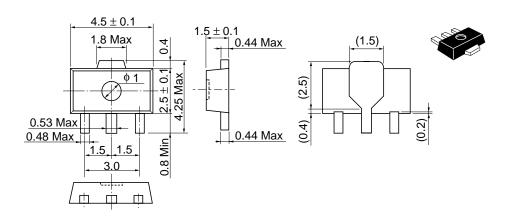








Unit: mm



Hitachi Code	UPAK
JEDEC	_
EIAJ	Conforms
Weight (reference value)	0.050 g

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